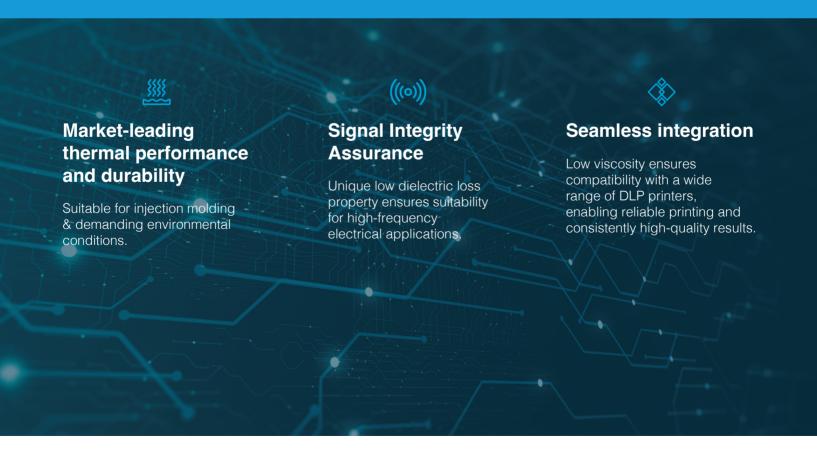
# NANODIMENSION

# **ATARU**

# A GROUNDBREAKING UV-CURABLE MATERIAL FOR DLP PRINTING

ATARU is engineered for exceptional hightemperature resistance and durability. ATARU also delivers excellent surface quality along with incredibly low dielectric loss.

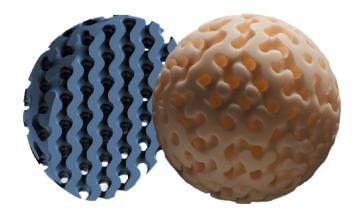




#### **KEY BENEFITS**

- High thermal performance and durability
- High impact strength
- Ultra low loss
- Excellent surface quality
- Fast processing





# **IDEAL APPLICATIONS**

- Injection Molding
- Molding under high pressure & temperature (carbon fiber molding)
- Tooling & fixtures
- Serial production (high speed curing time)
- Radio frequency RF (antenna)

# **ATARU PROPERTIES:**

# **Resin Properties**

Viscosity	~830 mPas (at 23° and 100 1/s)
Color	Cream Colored

#### **Mechanical Properties**

	Condition	Standard	Unit	Value
Tensile Modulus	1 mm/min	ISO 527-1/-2	MPa	5640
Strain at break	5 mm/min	ISO 527-1/-2	%	1.9
Stress at break	5 mm/min	ISO 527-1/-2	%	73
Flexural Modulus	1 %/min	ISO 178	MPa	5360
Flexural Strength	1 %/min	ISO 178	MPa	127
Flexural Strain at break	1 %/min	ISO 178	%	2.7
Izod impact strength unnotched	+22°C / 1 J	ASTM D4812 : 2006	J/m	236

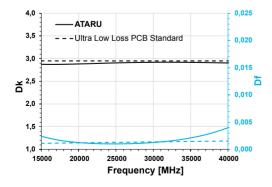
# **Thermo-Mechanical Properties**

CTE (0°C to 110°C)	3 K/min	IPC-TM-650 2.4.24.5	μm/(m·K)	45.0
CTE (110°C to 200°C)	3 K/min	IPC-TM-650 2.4.24.5	μm/(m·K)	72.6
CTE (200°C to 300°C)	3 K/min	IPC-TM-650 2.4.24.5	μm/(m·K)	116.3
Td2	10 K/min	IPC-TM-650	°C	351
Td5	10 K/min	IPC-TM-650	°C	378
Tg	10 K/min	IPC-TM-650	°C	>300°
HDT/B (0.45 MPa)	Flat	ISO 75-2:2013-08	°C	>300°
HDT/A (1.8 MPa)	Flat	ISO 75-2:2013-08	°C	>300°
HDT/C (8.0 MPa)	Flat	ISO 75-2:2013-08	°C	133

# **Thermal Properties**

Thermal Conductivity	25°C	W/mK	0.28
Thermal Conductivity	50°C	W/mK	0.29
Thermal Conductivity	100°C	W/mK	0.31
Spec. Heat Capacity	23°C	J/gK	0.97
Spec. Heat Capacity	200°C	J/gK	1.5

# **Dielectric Properties**



#### **Environmental Properties**

Water Absorption 24h ASTM D 570 % 0.09	
--	--

#### **PRINT PROCESS**

Recommended exposition time at 405nm under room temperature:

• 2.7 mW/cm<sup>2</sup>: 5.7 secs

• 3 mW/cm<sup>2</sup>: 5.2 secs

• 5.5-16 mW/cm<sup>2</sup>: 2.0-2.3 secs

• Base layer: 10 sec

Elevated temperature ease the release of large cross-sections. In case of flashing, add a delay before the exposition start.

#### **POST PRINT PROCESS**

#### 1. CLEANING

The Recommended cleaning agent is the mixture \*MMB:\*\*water 70:30 (w:w). The \*MMB: 3-Methoxy-3-methyl-1-butanol (MMB) / CAS: 56539-66-3

\*\*Deionized preffered

maximum soaking time in the cleaning agent is 15 minutes then the parts can be rinsed with water.

#### 2. DRYING

Dry under pressurized air or in an oven at a temperature of 90°C.

- 6x10s @50% (Hoenle UV Cube 100 IC)
- 2x30 min (CureBox Wicked Engineering)

#### 3. UV Post-curing

Any type of UV treatment is suitable (no risk of overcuring). Examples:

#### 4. Thermal Post-treatment

Heat 2h at 200°C and cool down slowly. For bulky parts, slow heating must be applied to allow the material to be heated evenly before it starts to cure. The ramp is dependent on the thickness the parts.

#### NANODIMENSION